

*Ref Enter  
of  
9-15-08*  
DOCKET NO: 278426US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :  
MITSUGU ABE, ET AL. : EXAMINER: ROSE, R.  
SERIAL NO: 10/549,294 :  
FILED: SEPTEMBER 16, 2005 : GROUP ART UNIT: 3723  
FOR: MATERIAL FOR PURIFICATION :  
OF SEMICONDUCTOR POLISHING  
SLURRY, MODULE FOR PURIFICATION  
OF SEMICONDUCTOR POLISHING  
SLURRY AND PROCESS FOR  
PRODUCING SEMICONDUCTOR  
POLISHING SLURRY

~~DO NOT ENTER: TAP/~~

03/25/2008

AMENDMENT

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Final Rejection dated November 16, 2007, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 9 of this paper.